OIPE JC22 MAY 31 2005 PATENT & TRADEMARK OFFICE

May 13, 2005

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

From: George O. Saile, Reg. No. 19, 572
28 Davis Avenue
Poughkeepsie, NY 12603

Subject: Application No. 10/759, 671 16 January 2004

Poon et al.

LASER ANNEAL COUPLED WITH RAPID THERMAL ANNEAL DUAL STEP SOURCE/DRAIN EXTENSION JUNCTION ANNEAL TO REDUCE THE JUNCTION DEPTH: MULIPLE-PULSE LOW ENERGY

Art Unit: 2812 Examiner: Walter L. Lindsay, Jr.

RESPONSE PATENT OFFICE ACTION

Dear Sir:

In response to the Office Action dated January 25, 2005, please amend the above identified application for patent as follows:

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner of Patents, PO Box 1450, Alexandria, VA 22313-1450, on May 25, 2005.

5/25/05

Stephen B. Ackerman
Reg. No. 37, 761

Amendments to the Specifications and Claims are reflected in the listing of claims which begins on page 3 of this document.

Remarks begin on page 10 of this document.